



# Research on Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalyst for CO<sub>2</sub> reforming of CH<sub>4</sub> prepared by atmospheric pressure glow discharge plasma jet

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## ABSTRACT

Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalyst had been prepared by atmospheric pressure glow discharge (APGD) plasma jet. Such plasma-prepared catalyst exhibited an improved low-temperature activity in CO<sub>2</sub> reforming of CH<sub>4</sub>, compared to that of the catalyst prepared by conventional method. Characteristics of catalysts were analyzed by means of X-ray powder diffraction (XRD), temperature programmed desorption (TPD) experiment with H<sub>2</sub> or CO<sub>2</sub> probe, Brunauer–Emmett–Teller (BET) procedure, transmission electron microscopy (TEM) and thermogravimetric analysis (TGA). The XRD and TEM characterization showed that this novel plasma-assisted preparation induced Ni nano-particles as small as 5 nm. The results of XRD, H<sub>2</sub>-TPD and TEM confirmed that, the nickel dispersion of the Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalyst by APGD was enhanced greatly. The improved anti-coke deposition performance was illustrated from the results of TGA, CO<sub>2</sub>-TPD and the stability test experiments.

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## 1. Introduction

The reaction of CO<sub>2</sub> reforming of CH<sub>4</sub> from two greenhouse gases to synthesis gas, a mixture of hydrogen and carbon monoxide, with its attracting industrial value and positive environment implication, had been of a great interest to the researchers. Intensive efforts had been devoted to investigate the more suitable catalyst for this reaction [1–12]. Nickel-based catalyst, among the investigated catalysts, was much promising for practical application because of its high activity and low cost. Therefore, a lot of works had been done to promote its low-temperature activity and coking-resistant ability. The effects of different promoters [1–5], supports [6–9] and preparing procedures [10–12] were investigated in order to improve its catalytic performance.

In recent years, the plasma technology had been employed to prepare new efficient catalyst because of its unique efficiency in the catalyst activation [10–33]. Vissokov et al. applied the electric arc plasma to the synthesis and regeneration of catalysts for natural gas reforming [13,14]. Phillips et al. studied generation of the supported Pd/C, Pd/Al<sub>2</sub>O<sub>3</sub> catalysts by plasma torch [15,16]. Liu

et al. investigated several plasma-assisted catalysts, e.g., Ni/Al<sub>2</sub>O<sub>3</sub> [12,17,18], Ir/Al<sub>2</sub>O<sub>3</sub> [19], Ni/SiO<sub>2</sub> [20], Pd/HZSM-5 [21], Pt/NaZSM [22] and Rh/Al<sub>2</sub>O<sub>3</sub> [23], with a method that the catalyst was firstly treated by vacuum glow discharge and then thermally calcined, and made a conclusion of the remarkable enhancement in the dispersion and low-temperature activity of the catalysts [24]. Chu et al. explored several glow discharge plasma-assisted new catalysts [25–28], such as the plasma-enhanced Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> [25], Ni/ $\alpha$ -Al<sub>2</sub>O<sub>3</sub> [26], Fischer–Tropsch cobalt catalysts [27] and Pd/ $\alpha$ -Al<sub>2</sub>O<sub>3</sub> samples [28]. These catalysts were treated by a radio frequency plasma, and there were higher catalytic performances than those of the catalysts prepared by thermal treatment. The applications of other plasma techniques, e.g., dielectric-barrier discharge [29], microwave plasma [30], corona discharge [31], induction discharge [32] and plasma-spraying technology [33] were also reported in the catalyst preparation.

In our previous works, the performances of plasma-enhanced nickel-based catalysts were investigated [10,11], and the advantages of the novel APGD plasma jet were presented, especially the PC&R method [11]. As the SiO<sub>2</sub>-supported nickel catalyst was easily deactivated in CO<sub>2</sub> reforming of CH<sub>4</sub> [4,34,35] and the  $\gamma$ -Al<sub>2</sub>O<sub>3</sub> sample was a more promising support [6,8], the new PC&R method was introduced to prepare the more efficient Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalyst in our work. The steps of conventional calcination and thermal reduction were omitted during the preparation process,

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and only APGD plasma jet was employed to decompose and reduce the catalyst precursor. Besides, the new samples prepared by this plasma technique were characterized and analyzed by XRD, H<sub>2</sub>-TPD, CO<sub>2</sub>-TPD, TEM, and TGA techniques. The catalytic performances in the reaction of CO<sub>2</sub> reforming of CH<sub>4</sub>, as well as the coke formation during reaction and the primary stability of these samples were also investigated.

## 2. Experimental

### 2.1. Sample preparation

The 12%Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalysts were prepared by three methods, using conventional thermal method (C) for comparison, PR method and PC&R method.

The preparation procedures: the  $\gamma$ -Al<sub>2</sub>O<sub>3</sub> support was first impregnated with an aqueous solution of Ni(NO<sub>3</sub>)<sub>2</sub> and dried at 110 °C for 5 h. Then it was divided into three parts. The first part for C sample was calcined at 550 °C for 5 h, and the resulting material was reduced at 750 °C in pure hydrogen for 2 h; The second for PR sample was conventionally calcined at 550 °C for 5 h, then reduced by plasma jet for 10 min; The third for PC&R sample was directly decomposed and reduced by plasma jet for 10 min.

Fig. 1 presented APGD plasma jet for catalysts preparation. An inside copper stick was connected to the high voltage supply. The coaxial stainless steel crust served as the grounded electrode. 20% H<sub>2</sub>/Ar with a flux of 1.5 m<sup>3</sup>/h was applied as the plasma-forming gas. When 20 kHz AC voltage was utilized, the plasma gas was jetted into the catalyst bed. Under the discharging conditions, the temperature of the catalyst bed was 527 °C.

### 2.2. Catalyst evaluation and characterization

#### 2.2.1. Catalyst evaluation

The catalytic evaluation was carried out in a fixed-bed reactor under 600–900 °C, a fixed CH<sub>4</sub>/CO<sub>2</sub> molar ratio of 4/6, and GHSV of 30 L/(g h). The GC7900 gas chromatograph (Shanghai Techcomp Instrument Ltd., China; the chromatographic column was TDX-01) was used to analyze the products. The conversions of methane and carbon dioxide, the yields of hydrogen and CO were defined habitually.

#### 2.2.2. XRD measurement

XRD patterns of samples were carried out in the DX-2500 (Dandong, China) diffractometer by using a Cu K $\alpha$  radiation at 36 kV and 28 mA. The scan rate was 0.11°/10 s for 2 $\theta$  ranging from 15° to 95°. The average nickel crystallite diameter was calculated by using Scherrer equation from all the Ni peaks.

$$d = \frac{0.89\lambda}{B \cos \theta} \times \frac{180^\circ}{\pi}$$

where  $d$  is the mean crystallite diameter,  $\lambda$  is the X-ray wavelength, and  $B$  is the full width half maximum (FWHM) of the Ni diffraction peak.

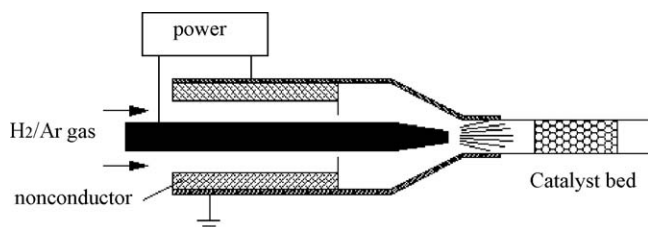


Fig. 1. Schematic of apparatus for APGD plasma jet.

#### 2.2.3. H<sub>2</sub>-TPD measurement

TPD experiment was carried out in a quartz tube. The sample (100 mg) was first held at 373 K for 1 h under flowing argon to remove physisorbed and/or weakly bound species. H<sub>2</sub> adsorption was occurring at 373 K by passing 10% (vol) H<sub>2</sub>/Ar mixed gas with a flow rate of 30 ml/min into the adsorption instrument. The TPD signal was recorded with the temperature increasing at a rate of 10 °C/min to 800 °C.

Based on the assumption that the H:Ni stoichiometric ratio was 1:1, the Ni dispersion could be calculated according to the TPD spectra [36,37].

$$D(\%) = \frac{N_{\text{surface}}}{N_{\text{total}}} \times 100 = \frac{N_{\text{H}_2} \times 2}{N_{\text{total}}} \times 100$$

Here,

$$N_{\text{H}_2} (\text{mol}) = \frac{S_{\text{TPD}}(V_{\text{loop}}/S_{\text{pulse}})}{24.5 \times 10^3 \text{ ml/mol}}$$

where  $N_{\text{surface}}$  is the mole number of nickel on the surface of catalysts, mol;  $N_{\text{total}}$  is the total mole number of nickel in the sample, mol;  $D$  is the catalyst dispersion;  $N_{\text{H}_2}$  is the mole number of H<sub>2</sub> uptake, mol; 24.5 is the mole volume of gas at the room temperature of 25 °C;  $S_{\text{TPD}}$  is the analytical area from TPD;  $V_{\text{loop}}$  is the loop calibration volume, ml; and  $S_{\text{pulse}}$  is the mean area of hydrogen pulses.

#### 2.2.4. CO<sub>2</sub>-TPD measurement

The sample (100 mg) was firstly held at 573 K for 1 h under flowing argon to remove physisorbed and/or weakly bound species. CO<sub>2</sub> adsorption was occurring at room temperature by passing 10% (vol) CO<sub>2</sub>/Ar mixed gas with a flow rate of 30 ml/min into the adsorption instrument. The TPD signal was recorded with the temperature increasing to 800 °C at a rate of 10 °C/min.

#### 2.2.5. BET characterization

The specific surface area and pore size distribution of the catalysts were determined by nitrogen adsorption by using a NOVA 1000e apparatus (Quantachrome, USA) at 77.35 K. The specific surface area was calculated by using the BET method while the pore size distribution was obtained from the adsorption isotherm by method of Barrett, Joyner and Halenda (BJH).

#### 2.2.6. TEM analysis

TEM analysis was performed on a TECNAI G<sup>2</sup> 20 S-Twin (FEI, USA) TEM apparatus.

#### 2.2.7. TGA characterization

TGA was performed in a TGA Q500 thermal analyzer. Air at flow rate of 50 ml/min was introduced into the instrument. Sample was loaded onto the thermo-balance and heated to 800 °C at a rate of 15 °C/min until a constant weight was obtained. The weight loss was recorded simultaneously.

## 3. Results and discussion

### 3.1. Catalytic performance

The catalytic activity of the Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalysts prepared by the three different methods was shown in Tables 1 and 2 with the reaction temperature varying from 650 °C to 850 °C. Though both of the conversions of CH<sub>4</sub>, CO<sub>2</sub> and the yields of H<sub>2</sub>, CO increased over the experimental temperature region for three kinds of catalysts, the plasma-assisted catalysts exhibited better catalytic performance, compared to the conventional catalyst. Especially the Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalyst by the PC&R method presented excellent low-temperature activity.

**Table 1**CH<sub>4</sub> and CO<sub>2</sub> conversions over the different Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalysts.

Catalyst	Conversion (%)									
	650 °C		700 °C		750 °C		800 °C		850 °C	
	CH <sub>4</sub>	CO <sub>2</sub>	CH <sub>4</sub>	CO <sub>2</sub>	CH <sub>4</sub>	CO <sub>2</sub>	CH <sub>4</sub>	CO <sub>2</sub>	CH <sub>4</sub>	CO <sub>2</sub>
Ni/ $\gamma$ -Al <sub>2</sub> O <sub>3</sub> (C)	36.4	35.0	48.5	42.8	62.9	52.4	80.3	64.4	91.6	69.7
Ni/ $\gamma$ -Al <sub>2</sub> O <sub>3</sub> (PR)	39.2	37.2	51.7	46.0	67.2	57.8	85.4	69.1	95.8	75.7
Ni/ $\gamma$ -Al <sub>2</sub> O <sub>3</sub> (PC&R)	43.7	36.9	60.9	50.0	79.7	61.6	94.2	73.8	98.4	80.6

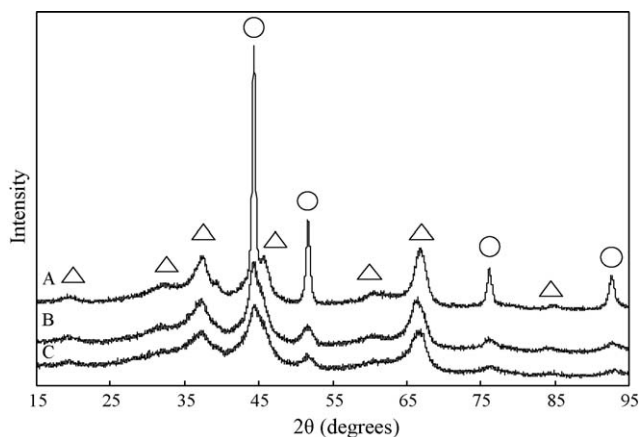
Reactions conditions: catalyst 200 mg, Ni loading 12%, GHSV = 30 L/(g h) and CH<sub>4</sub>/CO<sub>2</sub> molar ratio = 4/6.**Table 2**H<sub>2</sub> and CO yields (%) over the different catalysts.

Catalyst	Yield (%)									
	650 °C		700 °C		750 °C		800 °C		850 °C	
	H <sub>2</sub>	CO	H <sub>2</sub>	CO	H <sub>2</sub>	CO	H <sub>2</sub>	CO	H <sub>2</sub>	CO
Ni/ $\gamma$ -Al <sub>2</sub> O <sub>3</sub> (C)	34.7	33.5	47.0	40.9	62.0	51.8	79.1	62.9	90.1	67.7
Ni/ $\gamma$ -Al <sub>2</sub> O <sub>3</sub> (PR)	37.5	35.9	50.3	44.5	66.2	56.7	84.0	68.1	94.3	74.1
Ni/ $\gamma$ -Al <sub>2</sub> O <sub>3</sub> (PC&R)	42.9	36.0	59.8	49.1	79.1	61.3	93.7	72.7	97.9	79.5

Reactions conditions: catalyst 200 mg, Ni loading 12%, GHSV = 30 L/(g h) and CH<sub>4</sub>/CO<sub>2</sub> molar ratio = 4/6.

### 3.2. XRD results

Fig. 2 presented the XRD patterns of the Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (C), Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PR) and Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PC&R) samples. From Fig. 2A, the conventional Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> owned the peaks with  $d = 2.04, 1.76, 1.25, 1.06$  which were assigned to metallic Ni phase, and the peaks with  $d = 4.60, 2.81, 2.41, 1.99, 1.52, 1.41, 1.15$  which were assigned to alumina phase. For the plasma-activated Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PR) and Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PC&R) catalysts, the metallic Ni phase and the alumina phase also could be seen, as shown in Fig. 2B and C. But the nickel characteristic peaks of the plasma-assisted samples were much broader, compared to those of the Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (C) catalyst. This indicated that the Ni particle size of Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PR) and Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PC&R) was smaller than that of Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (C). The nickel particle size of the three samples was calculated by Scherrer formula. The Ni size was 17.8 nm for Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (C), but it was only 5.4 nm for Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PR) and 5.0 nm for Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PC&R). The smaller nickel particle size inevitably brought about increasing in Ni dispersion and higher activity as well as better anti-carbon deposit performance of the catalyst, which was responded by following experiments.

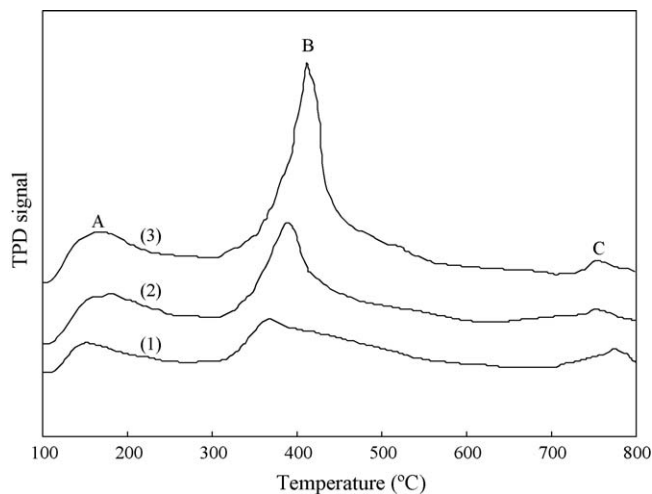


**Fig. 2.** XRD patterns of the 12%Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalysts. (A) C, (B) PR and (C) PC&R; ( $\Delta$ ) Al<sub>2</sub>O<sub>3</sub> and ( $\circ$ ) Ni.

### 3.3. H<sub>2</sub>-TPD characterization

H<sub>2</sub>-TPD curves for 12%Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalysts prepared by various methods were presented in Fig. 3. Peak A presented a very weak form of molecular adsorption below 200 °C. Peaks B and C were related to very strong bound chemisorption sites. From Fig. 3, the chemisorbed hydrogen amount increased in accordance with the order of Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (C), Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PR) and Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PC&R), which showed that the Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PC&R) samples exhibited largest hydrogen adsorption capacity, and the conventional sample showed the least.

The Ni dispersion data calculated according to the TPD spectra were listed in Table 3. The conventional Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (C) catalyst presented a Ni dispersion of 14.7%, while it was 22.1% and 30.6% for the plasma-activated Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PR) and Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PC&R) catalysts, respectively. The results showed that the application of the plasma jet greatly improved the hydrogen adsorption capacity of Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalyst, and more active sites existed over the surface of the catalysts, especially the Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalyst by the PC&R method, which was in good agreement with the results obtained from the XRD characterization.



**Fig. 3.** H<sub>2</sub>-TPD patterns of the Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> samples prepared by different methods. (1) C, (2) PR and (3) PC&R.

**Table 3**  
H<sub>2</sub>-TPD results of Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> samples prepared by different methods.

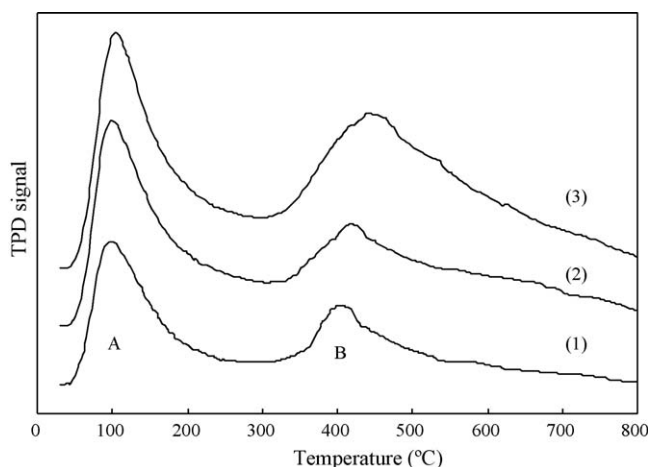
Samples	H <sub>2</sub> desorbed ( $\mu$ mol/g)	Dispersion (%)
Ni/ $\gamma$ -Al <sub>2</sub> O <sub>3</sub> (C)	150.7	14.7
Ni/ $\gamma$ -Al <sub>2</sub> O <sub>3</sub> (PR)	225.8	22.1
Ni/ $\gamma$ -Al <sub>2</sub> O <sub>3</sub> (PC&R)	312.5	30.6

TPD results presented a nickel dispersion with the order of Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (C) < Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PR) < Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PC&R), which could be attributed to the different treatment processes. For Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (C) sample, the metallic nicks were easily sintered and conglomerated during the long-time, high-temperature process, such as calcination at 550 °C for 5 h and reduction at 750 °C for 2 h. For Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PC&R) sample, there were large amount of H atoms and other high-energy particles in the plasma jet, so it could decompose the precursor of Ni(NO<sub>3</sub>)<sub>2</sub>/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> and reduce the NiO/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> effectively in a kindly temperature environment and shorter process time, and avoid the conglomeration and sintering of the metallic nickel. At the meantime, the bombardment of the charged particles in the plasma jet on the surface of catalysts also benefited nickel dispersion. As a result, the Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PC&R) sample presented higher Ni dispersion with the average nickel diameter of only 5 nm.

### 3.4. CO<sub>2</sub>-TPD characterization

CO<sub>2</sub>-TPD curves for 12%Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalysts prepared by three methods were presented in Fig. 4. Peak A presented a weak Lewis alkaline site adsorbed at 100 °C. Peak B presented a strong Lewis alkaline site adsorbed at 400–500 °C.

The chromatographic areas of peaks A and B calculated according to the CO<sub>2</sub>-TPD spectra of three samples were listed in Table 4. Obviously, the B-peak areas of Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (C) catalyst were smaller than those of Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PR and PC&R) catalysts. Compared to the conventional catalyst, the areas of A-peak and B-peak of PC&R catalysts were increased about 71.2% and 165.7%, respectively. Li et al. [38] reported CO<sub>2</sub> adsorption took place on the support surface but not on the Ni particle. Because CO<sub>2</sub> was acid gas, it could only be adsorbed on the alkaline site of support surface. The increase in peak areas of CO<sub>2</sub>-TPD showed that the alkalescence of support surface treated by plasma was improved significantly. It benefited to the carbon deposition elimination and increased the coking-resistant ability of catalyst surface.



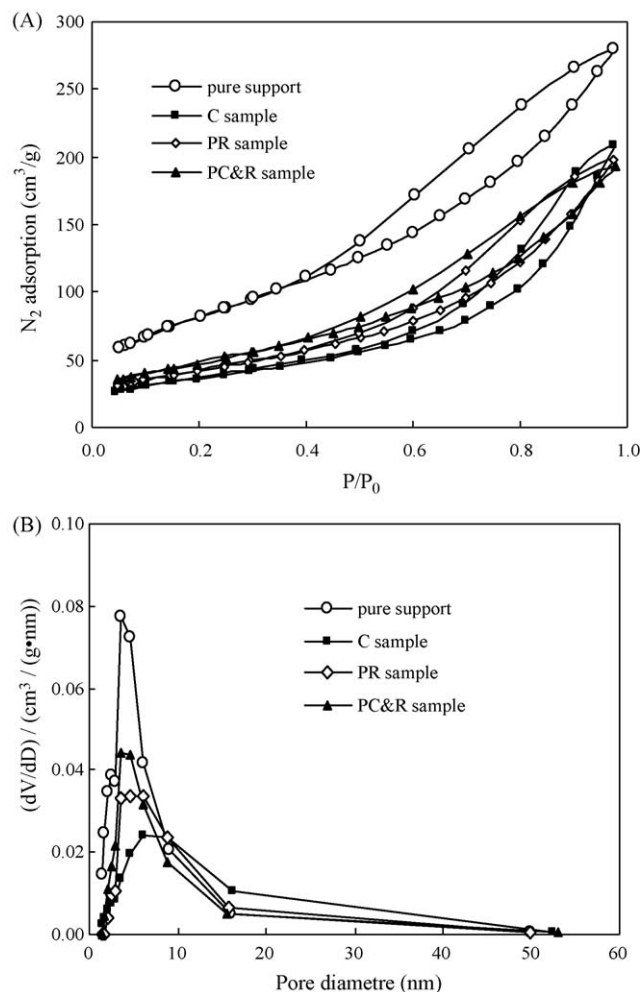
**Fig. 4.** CO<sub>2</sub>-TPD patterns of the Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalysts. (1) C, (2) PR and (3) PC&R.

**Table 4**  
CO<sub>2</sub> desorption peak area over different Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> samples.

Sample	CO <sub>2</sub> desorption peak area (a.u.)	
	Peak A	Peak B
12%Ni/ $\gamma$ -Al <sub>2</sub> O <sub>3</sub> (C)	7.98	6.06
12%Ni/ $\gamma$ -Al <sub>2</sub> O <sub>3</sub> (PR)	11.84	9.66
12%Ni/ $\gamma$ -Al <sub>2</sub> O <sub>3</sub> (PC&R)	13.66	16.10

### 3.5. BET characterization

N<sub>2</sub> adsorption experimental results were shown in Fig. 5. The difference in the pore size of Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PC&R), Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PR) and Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (C) was significant. It seemed strange that, from Table 5 and the pore size distribution curves, the average pore diameter of the three Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalysts had an increase compared to that of the  $\gamma$ -Al<sub>2</sub>O<sub>3</sub> support, especially, the most obvious change in average pore diameter of Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (C) was from 5.8 nm to 9.8 nm. It was probably due to the sintering of support and the diffusing of Ni particle into support pores with smaller size. Because the sintering of support produced larger pores, the diffusing of Ni particle into support plugged the smaller pores, both brought about the changes of pore size distribution of catalysts, as shown in Fig. 5, so the average pore diameter of the three Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalysts changed. However, Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PC&R) sample, due to shorter treatment time and omitting of long-time,



**Fig. 5.** N<sub>2</sub> adsorption-desorption isotherms and resulting pore size distribution of  $\gamma$ -Al<sub>2</sub>O<sub>3</sub> support and different 12%Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalysts.



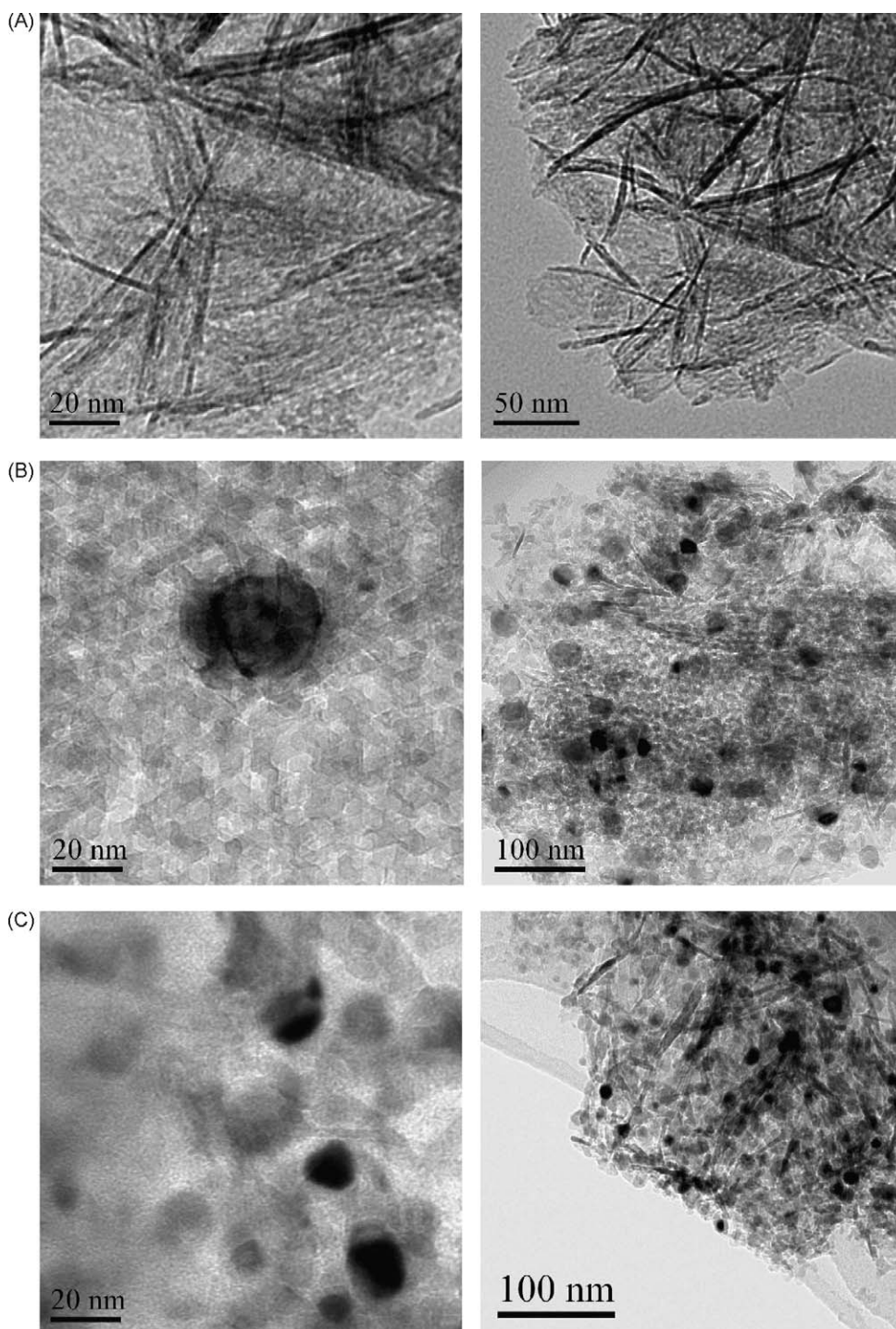
**Table 5**Texture of pure  $\gamma$ -Al<sub>2</sub>O<sub>3</sub> support and different 12%Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> catalysts.

Sample	Average pore diameter (nm)	Specific surface area (m <sup>2</sup> /g)
Pure $\gamma$ -Al <sub>2</sub> O <sub>3</sub> support	5.8	299.3
Ni/ $\gamma$ -Al <sub>2</sub> O <sub>3</sub> (C)	9.8	131.6
Ni/ $\gamma$ -Al <sub>2</sub> O <sub>3</sub> (PR)	8.0	153.4
Ni/ $\gamma$ -Al <sub>2</sub> O <sub>3</sub> (PC&R)	6.9	173.6

high-temperature process, effectively avoided sintering and plugging, and furthest kept its original feature. Therefore, a higher specific surface area was obtained by plasma process, which benefited the good performance of catalysts.

### 3.6. TEM analysis

Fig. 6 showed the TEM images of the catalysts. From these images, the smaller size of nickel particle, and the higher nickel dispersion, no obvious sintering and conglomeration were observed for the plasma-activated samples, compared to those



**Fig. 6.** TEM images of Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub>. (A)  $\gamma$ -Al<sub>2</sub>O<sub>3</sub>, (B) Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (C), (C) Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PR) and (D) Ni/ $\gamma$ -Al<sub>2</sub>O<sub>3</sub> (PC&R).

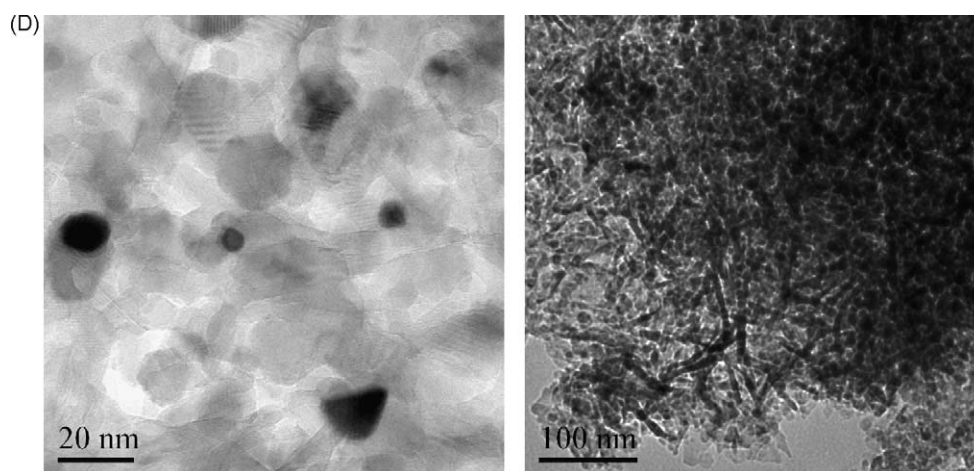


Fig. 6. (Continued).

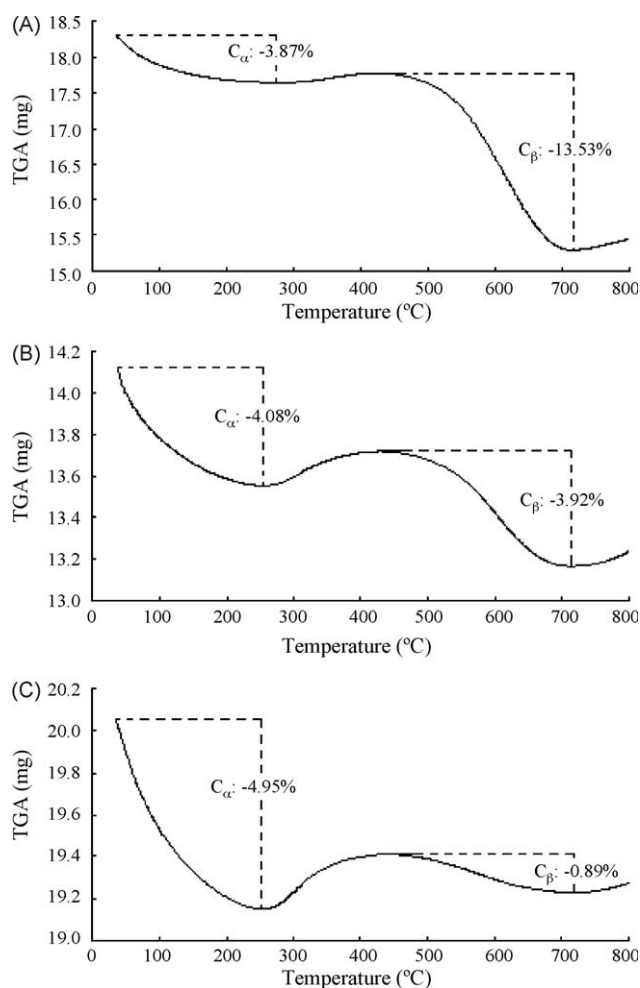
of conventional one. These results well supported the conclusions obtained from the XRD and TPD characterization.

### 3.7. TGA characterization

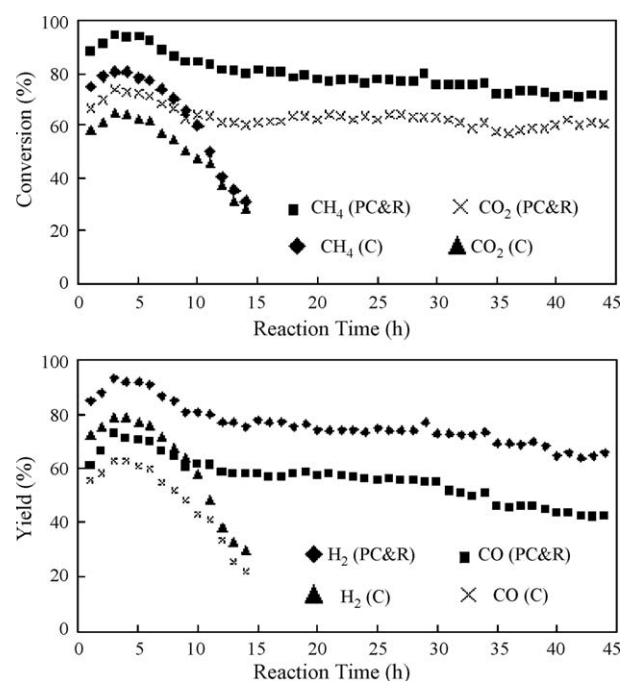
Zhang and Verykios [39] reported that three kinds of carbonaceous species formed on the surface of Ni/Al<sub>2</sub>O<sub>3</sub> catalyst by TGA, and designated as C<sub>α</sub> at 150–220 °C, C<sub>β</sub> at 530–600 °C and

C<sub>γ</sub> at >650 °C. The C<sub>α</sub> was an active carbonaceous species which was responsible for the formation of synthesis gas, while C<sub>γ</sub> was responsible for catalyst deactivation. The C<sub>β</sub> was a surface poison or spectator at low reaction temperature (<530 °C), but they might participate in CO formation, to a small extent, at high temperature (>600 °C). However, the C<sub>β</sub> could change into C<sub>γ</sub> when time of exposure was longer than 2 h.

The TGA results of Ni/γ-Al<sub>2</sub>O<sub>3</sub> catalysts after reaction were shown in Fig. 7. The total carbon amount formed on the surface of Ni/γ-Al<sub>2</sub>O<sub>3</sub> (C) was up to 17.4%, while it was 8.00% for Ni/γ-Al<sub>2</sub>O<sub>3</sub> (PR) and only 5.84% for Ni/γ-Al<sub>2</sub>O<sub>3</sub> (PC&R). Especially, most of the carbonaceous species on the surface of Ni/γ-Al<sub>2</sub>O<sub>3</sub> (PC&R) were the active C<sub>α</sub>, and only 0.89% C<sub>β</sub> was found. On contrast, on the conventional catalyst, the active C<sub>α</sub> and the C<sub>β</sub> were 3.87% and 13.53%, respectively. It suggested that the plasma activation induce modifications of the catalyst structure, and the novel catalyst prepared by plasma jet exhibit better anti-carbon deposit performance than that of conventional catalyst. Another surprising



**Fig. 7.** TGA profile of the conventional and plasma-activated Ni/γ-Al<sub>2</sub>O<sub>3</sub> catalysts. Conditions: Ni loading 12%, reaction temperature = 800 °C, GHSV = 30 L/(g h), CH<sub>4</sub>/CO<sub>2</sub> molar ratio = 4/6 and reaction time = 5 h. (A) C, (B) PR and (C) PC&R.



**Fig. 8.** The stability test results of the conventional and plasma-activated Ni/γ-Al<sub>2</sub>O<sub>3</sub> (PC&R) catalysts. Conditions: catalyst 100 mg, Ni loading 12%, reaction temperature = 800 °C, GHSV = 60 L/(g h) and CH<sub>4</sub>/CO<sub>2</sub> molar ratio = 4/6.

thing was that, on the three catalysts, no  $C_\gamma$  can be found. From the results, the sequence of the ability of anti-carbon deposit was:  $Ni/\gamma-Al_2O_3$  (PC&R) >  $Ni/\gamma-Al_2O_3$  (PR) >  $Ni/\gamma-Al_2O_3$  (C). It was agreed with the results obtained by Martinez et al. that Ni particles with diameters below 9 nm would be benefit for resistance of coke formation [5], because the nickel particle size of plasma-assisted  $Ni/\gamma-Al_2O_3$  (PC&R) sample was only 5 nm in current experiments.

### 3.8. Stability test results

The stability tests of  $Ni/\gamma-Al_2O_3$  (C) and  $Ni/\gamma-Al_2O_3$  (PC&R) were conducted at 800 °C. The results were shown in Fig. 8. Though there is a decrease in activity for both  $Ni/\gamma-Al_2O_3$  (C) and  $Ni/\gamma-Al_2O_3$  (PC&R) samples after an initial increase, the conventional  $Ni/\gamma-Al_2O_3$  catalyst showed a faster deactivation. After 14 h reaction, the  $CH_4$  and  $CO_2$  conversions for  $Ni/\gamma-Al_2O_3$  (C) changed from 80.3% and 64.4% to 31.5% and 28%, respectively. Similarly,  $H_2$  and CO yields were reduced from 79.1% and 62.9% to 30.0% and 22.1%, respectively. For the  $Ni/\gamma-Al_2O_3$  (PC&R) catalyst, the decrease rate in conversions and yields was relatively slow after 44 h reaction. It indicated that the  $Ni/\gamma-Al_2O_3$  (PC&R) catalyst possessed good stability. The stability test results were in agreement with the TGA measurement, as the coke formation was the main reason for catalyst deactivation in  $CO_2$  reforming of  $CH_4$ .

## 4. Conclusions

In this work, a novel plasma-assisted calcination and reduction (PC&R) method was employed to prepare the new  $Ni/\gamma-Al_2O_3$  catalysts. The catalysts prepared by PC&R method showed a high catalytic activity and an excellent anti-carbon deposit performance in  $CO_2$  reforming of  $CH_4$ , it profited from its smaller Ni particle size of only 5 nm, which enhanced nickel dispersion. Both of the smaller Ni particle size and enhanced nickel dispersion profited from the short treatment time of only 10 min in plasma process instead of several hours in conventional calcinations for decomposing and reducing catalyst precursor of  $Ni(NO_3)_2/\gamma-Al_2O_3$ . And the short treatment time profited from the action between catalyst precursor and large amount of H atoms in plasma process instead of  $H_2$  in conventional process.

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